PROCEDURE FOR CLEANING METALS LABWARE

1. SCOPE AND APPLICATION

This method describes the necessary steps to be taken to ensure labware is free of significant metals contamination. It is to be used when cleaning microwave digestion vessels and liners, general laboratory glassware and hardware, SPLP (Synthetic Precipitation Leachate Procedure) and TCLP (Toxicity Characteristic Leachate Procedure) filtration apparatus, volumetric glassware, polypropylene funnels, Teflon beakers, watch glasses, spatulas, and mortar and pestles, etc. Before analysis, samples must be digested in meticulously cleaned vessels to aide in the control and elimination of contamination.

2. APPARATUS AND EQUIPMENT

2.1. Plastic buckets (no metal)

2.2. Scrubbing brushes

3. REAGENTS AND CHEMICALS

3.1. Deionized (DI) water

3.2. Citranox detergent

3.3. Trace Metal Grade Nitric Acid (HNO_3) - The expiration date is provided by the manufacturer. Stored in the fume hood cabinet at room temperature.

3.4. Trace Metal Grade Hydrochloric Acid (HCl) - The expiration date is provided by the manufacturer. Stored in the fume hood cabinet at room temperature.

4. PROCEDURE FOR CLEANING MICROWAVE DIGESTION VESSELS

4.1. The microwave vessels and caps must be cleaned after each digestion. In the fume hood, fill an appropriate container with 50 % HCl. Soak all vessels and caps overnight. The following morning, rinse each vessel and cap three times with DI water. Then, in the fume hood, fill an appropriate container with 50 % HNO_3. Soak all vessels and caps overnight. The following morning, rinse each vessel and cap three times with DI water. Allow the vessels and caps to dry by placing them upside down on a Kimwipe. As soon as they are dry, cap each vessel and store on a laboratory shelf.

Alternative vessel and cap cleaning procedure - After the vessels are used for a digestion, rinse three times with DI water and allow to dry. Add 5 mL of concentrated HNO_3 to each vessel, cap, and place in the microwave. Run the microwave for 10 m at 650 W. Appropriately discard the HNO_3. Rinse each vessel and cap three times with DI water and allow to dry upside down on a Kimwipe. As soon as the vessels are dry, cap, and place on a laboratory shelf.

The OFFICIAL COPY is the on-line version. All other copies are considered unofficial and uncontrolled.

5. PROCEDURE FOR CLEANING TCLP AND SPLP FILTRATION APPARATUS

5.1. Fully disassemble the filtration apparatus including all O-rings and thoroughly rinse each piece with DI water.

5.2. Add about 1 L of DI water to a plastic bucket and add 5 capfuls of Citranox detergent. Thoroughly scrub each piece with a test tube brush and the diluted Citranox detergent solution. It is important to have several sizes of test tube brushes that are in good condition for proper cleaning.

5.3. Thoroughly rinse each piece of labware with DI water.

5.4. If there is potential for contamination, e.g., a high concentration sample has been processed prior to the cleaning, the filtration apparatus must be verified to be clean. Filter about 250 mL of the extraction buffer through a cleaned filtration apparatus with a filter in place and have the filtrate analyzed for contaminants of interest. If the filtrate is within acceptable limits, as determined by the metals group supervisor, then the filtration apparatus may be used as is without changing the filter used to test the cleanliness of the apparatus. However, if the filtrate is determined to be unacceptable by the metals group supervisor then the apparatus must go through the cleaning procedure again.

5.5. In addition to scrubbing with Citranox solution, the filtration apparatus may be soaked in a 10 % HNO_3 solution (no longer than 30 minutes) and rinsed with DI water. See section 7.1 for acid discard procedure.

6. PROCEDURE FOR CLEANING VOLUMETRIC FLASKS

6.1. Properly dispose of any metals waste left in the flask into a metals waste container according to the procedure in section 7.

6.2. Remove all labels. Writing made with a permanent type marker can be removed by rubbing with a Kimwipe wetted with methanol.

6.3. Rinse once with DI water.

6.4. While working inside the fume hood, add 20 mL of HNO_3 and 10 mL of HCL to the empty 1 L volumetric flask. Cap the volumetric and invert several times to rinse the interior with the acid solution. Discard the concentrated acid (see section 7.1). Less acid may be used to clean smaller flasks.

6.5. While continuing to work in the fume hood, use another clean container to slowly transfer DI water into the volumetric flask that was rinsed with nitric and hydrochloric acids until it is completely filled.

Note: The addition of DI water to the volumetric flask containing concentrated nitric and hydrochloric acid rinsate will liberate irritating acid fumes. Care must be taken to protect the work environment from concentrated acid fumes.

6.6. Discard the dilute acid solution into the sink while flushing with a generous amount of tap water.

The OFFICIAL COPY is the on-line version. All other copies are considered unofficial and uncontrolled.

6.7. Rinse the volumetric flask several times with DI water.

6.8. Store the volumetric flask completely filled with DI water with the cap securely in place.

7. SAFETY/HAZARDOUS WASTE MANAGEMENT

7.1. Citranox should be disposed of down the sink with plenty of tap water. Acids should be properly diluted before discarding down the drain. An acid solution diluted to a 2 % acid concentration or diluted by 50 or greater will be neutralized by the laboratory's neutralization system prior to being released to the sewer.

7.2. Protective eyewear, lab coats, and gloves must be worn when working with acids and strong detergents.

7.3. Metals Waste Disposal:

All spikes, PQLs, and samples should be neutralized and discarded down the sink with plenty of water unless the sample has a metal concentration that exceeds the following limits established for sewer discharge,

As 132 µg/L	Pb 540 µg/L	Cu 852 µg/L
Cd 79 µg/L	Hg 38 µg/L	Mo 105 µg/L
Cr 2898 µg/L	Ni 1428 µg/L	Zn 2730 µg/L
Se 353 µg/L	Ag 3190 µg/L	

Samples above these limits should be discarded in the appropriate hazardous waste container and not down the sink.

8. REFERENCES

8.1. Laboratory Health and Safety Plan.

8.2. City of Tallahassee Industrial Pretreatment Sewer Use Manual, located on the City of Tallahassee website, Talgov.com.

Appendix of Significant Changes

01/15/2009 Section 1 - addition of general glassware and hardware.

01/11/2010 Section 4 - addition of a nitric acid rinse.

Section 6 - detail added for clarification

Section 7.2.1 - Updated the sewer discharge limits according to the City of Tallahassee Industrial Pretreatment Sewer Use Manual, section 21-356 Specific Pollutant Limitations. Located at Talgov.com

The OFFICIAL COPY is the on-line version. All other copies are considered unofficial and uncontrolled.

01/06/2011 Section 5- added HNO_3 rinse for TCLP/SPLP filtration vessels.

The OFFICIAL COPY is the on-line version. All other copies are considered unofficial and uncontrolled.